

IN THE SPECIFICATION

Please rewrite the paragraph beginning on page 42, line 24, and ending on page 43, line 8, as follows:

Regarding a vacuum chamber, it is preferable for the inner walls of the vacuum chamber to be controlled at not lower than a temperature at which the organometal gases can have sufficiently high vapor pressure and not higher than a decomposition temperature of the organometal gases. The reason for that is because the organometal gases and their decomposed products have to be ~~refrained~~ prevented from adhering to the inner walls of the vacuum chamber and the temperature control is effective to improve the in-plane evenness of the film thickness and to suppress particle formation.